R30-4 gun S&A during electrode assembly installation and laser retro-reflection evaluation with various pucks Including CMM on Puck #35

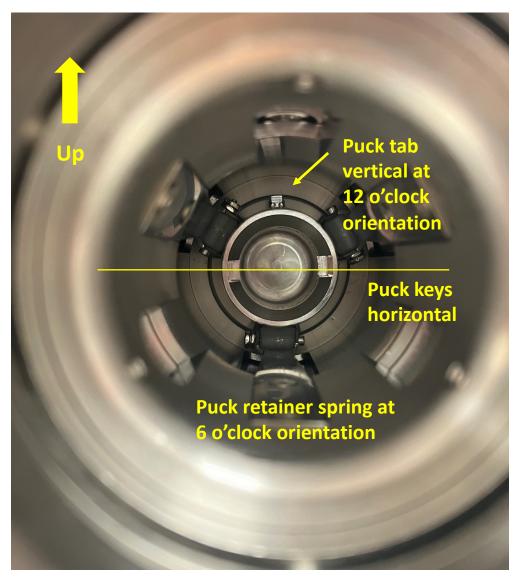
C. Hernandez-Garcia, G. Palacios-Serrano, M. Stutzman, S. Zhang,B. Mares, C. Gould, S. Hardisty, R. Ammons, E. MosbyMay 8, 2024

R30-4 gun electrode assembled on April 25, 2024 with 16/30 front end





R30-4 gun puck retainer assembly orientation



R30-4 back end zoomed in showing orientation of puck retainer assembly to be used for installing puck with ear (tab) up

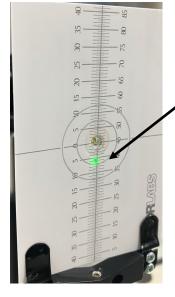
S&A setup to evaluate laser retro-reflection with R30-4 Puck plane electrode installed to gun high voltage chamber (mirror or GaAs) Reflected laser spot measuring plane (card with pinhole) The electrode z-axis is tilted down 0.124 deg with respect to chamber z-axis 532 nm laser beam path Y reflected laser spot displacement (mm) Reflected light angle is 2 X electrode angle D = 1380 mm

S&A reports that the electrode z-axis is 0.124 deg pointing down wrt to the gun HVC z-axis

First with the laser launch colinear with R30-4 gun high voltage chamber

Mirror puck ear up





z-axis Mirror puck θ =atan($^{Y}/_{D}$)

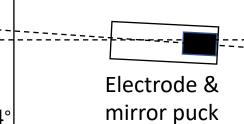
Y = 6 mm

D = 1380 mm

Reflection θ = 0.249°

Electrode z-axis angle = $\theta/2 = 0.124^{\circ}$

High voltage chamber



High voltage chamber

Electrode &

puck # 35

 $\theta = 0.124^{\circ}$

 θ = 0.312 °

Agrees with S&A measurement

GaAs wafer on Moly puck # 35 ear up





GaAs on Moly puck #35. θ =atan($^{Y}/_{D}$)

Y = 15 mm D = 1380 mmReflection $\theta = 0.624^{\circ}$

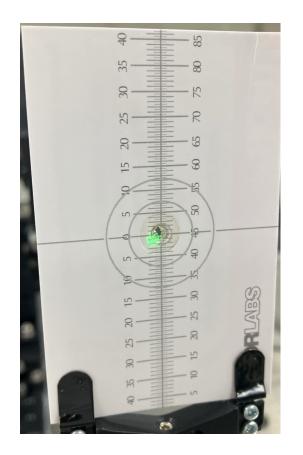
GaAs puck # 35 z-axis angle = $\theta/2$ = 0.312°

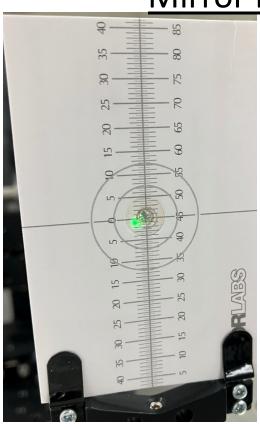
Is the Moly puck z-axis tilted? Or is the GaAs wafer plane tilted wrt to the moly puck z-axis?

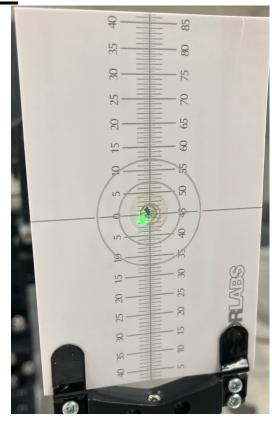
Next, and for the rest of measurements, the laser launch was made

colinear with R30-4 gun electrode z-axis

Mirror Puck





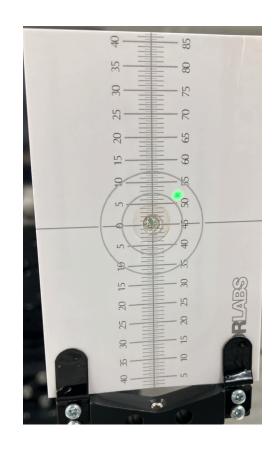


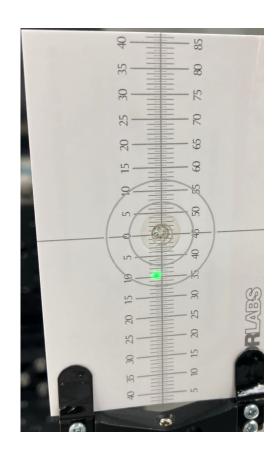
Y = 1.5 mm D = 1380 mm Reflection θ = 0.062°

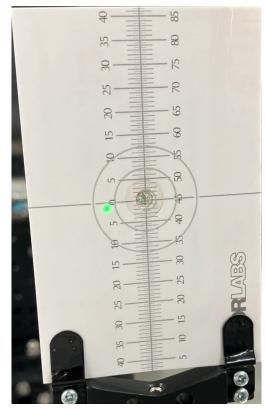
Mirror puck z-axis angle = $\theta/2 = 0.031^{\circ}$

Ear to the left Ear up Ear to the right

Laser colinear with R30-4 gun electrode z-axis Bulk GaAs on Puck # 35



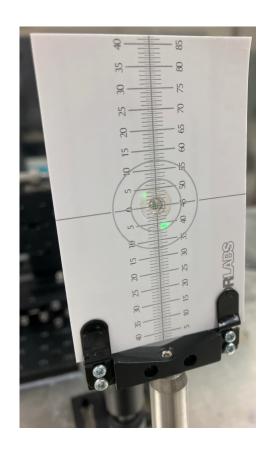


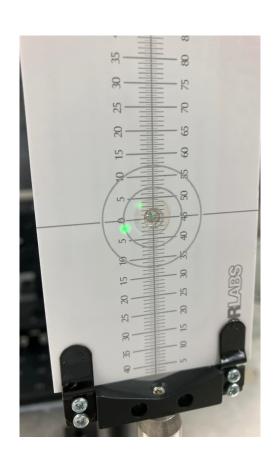


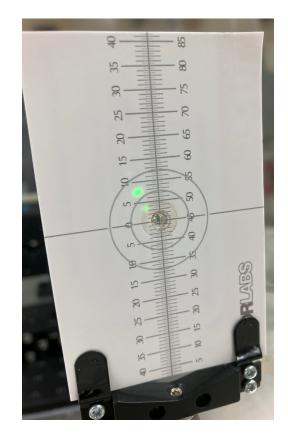
Y = 10 mm D = 1380 mm Reflection θ = 0.416°

Bulk GaAs on puck # 35 z-axis angle = $\theta/2 = 0.208^{\circ}$

Laser colinear with R30-4 gun electrode z-axis SSL GaAs on Puck # 31







Y = 7 mm D = 1380 mm Reflection θ = 0.290°

SSL GaAs on puck # 31 z-axis angle = $\theta/2 = 0.145^{\circ}$

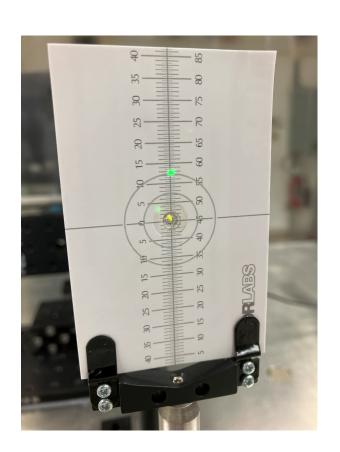
Ear to the left Ear up Ear to the right

Laser colinear with R30-4 gun electrode z-axis SSL GaAs on Puck # 10

Y = 13 mm D = 1380 mm Reflection θ = 0.540°

SSL GaAs on puck # 10 z-axis angle = $\theta/2 = 0.270^{\circ}$



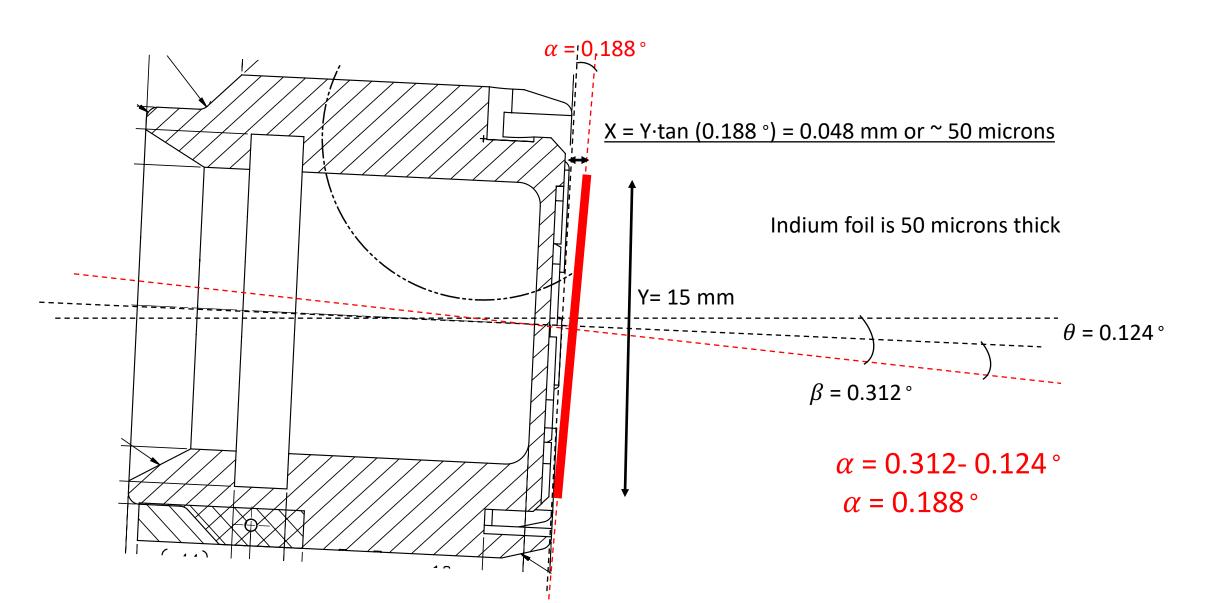


Inadvertently I missed taking the picture with the ear to the right

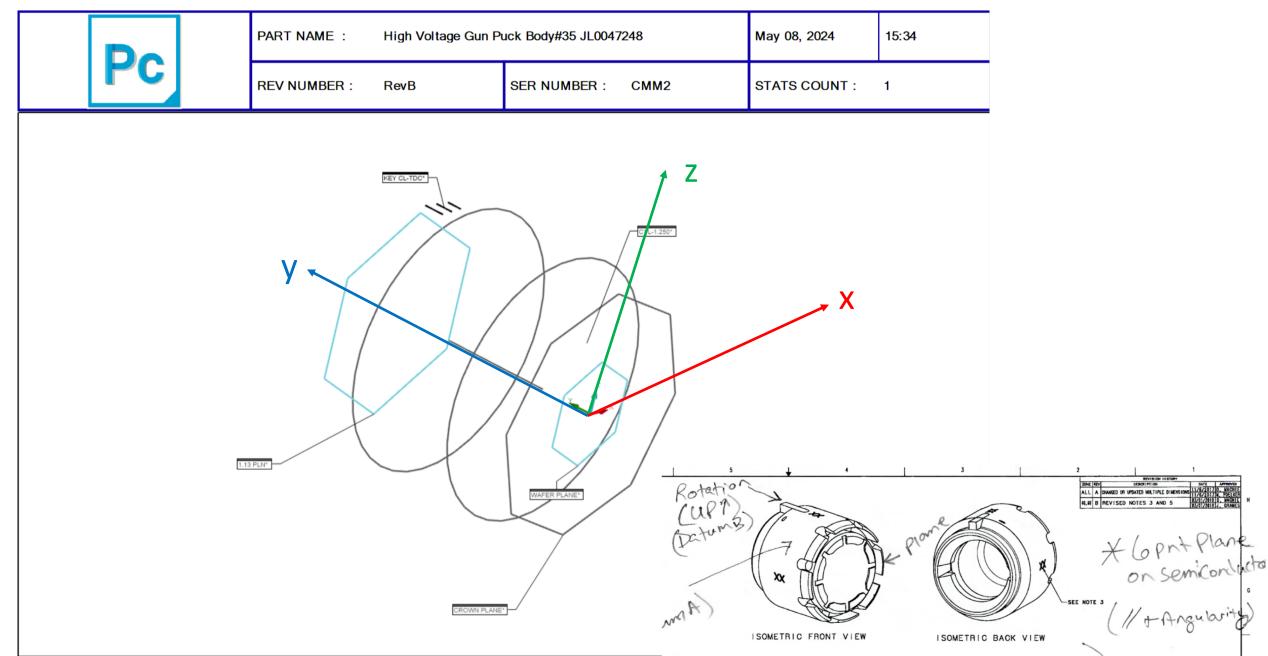
Ear to the left

Ear up

Based solely on laser retro-reflection spot displacement measurements. the GaAs wafer plane seems to be tilted 0.188° down wrt to the puck z-axis



Puck # 35 with bulk GaAs was sent to SRF Coordinate Measuring Machine (CMM)



The CMM results show that:

- The crown plane is tilted up wrt the puck z-axis by 0.0574°
- The wafer plane is tilted down wrt the puck z-axis by 0.1729°

⊿	DEG	ANGL2 - CRO	ANGL2 - CROWN PLANE TO YAXIS						
AX		NOMINAL	+TOL	-TOL	MEAS	DEV	OUTTOL		
А		270.0000	0.1000	0.1000	269.9426	-0.0574	0.0000		
∠	DEG	ANGL4 - CRC	ANGL4 - CROWN PLANE TO XAXIS						
AX		NOMINAL	+TOL	-TOL	MEAS	DEV	OUTTOL		
А		360.0000	0.1000	0.1000	359.9918	-0.0082	0.0000		
∠	DEG	ANGL6 - WA	FER PLANE TO YA	XIS					
AX		NOMINAL	+TOL	-TOL	MEAS	DEV	OUTTOL		
Α		270.0000	0.1000	0.1000	270.1719	0.1719	0.0719		
∠	DEG	ANGL7 - WAFER PLANE TO YAXIS							
AX		NOMINAL	+TOL	-TOL	MEAS	DEV	OUTTOL		
Α		90.0000	0.1000	0.1000	89.8281	-0.1719	0.0719		
←→	IN	DIST1 - 1.13	DIST1 - 1.13 PLN TO CROWN PLANE						
AX		NOMINAL	+TOL	-TOL	MEAS	DEV	OUTTOL		
М		1.1300	0.0100	0.0100	1.1325	0.0025	0.0000		